

35397 U.S. PTO  
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PATENT NUMBER and  
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10006633	FILING DATE 12/05/2001	CLASS 430	SUBCLASS 18	GAU 1737	EXAMINER WALKE
<b>**APPLICANTS:</b> Kong Keun; Park Gyu; Jung Jae; Shin Ki;					
<b>**CONTINUING DATA VERIFIED:</b>					
<b>** FOREIGN APPLICATIONS VERIFIED:</b> REPUBLIC OF KOREA 2000-82823 12/27/2000					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no 35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no Verified and Acknowledged Examiners's initials				ATTORNEY DOCKET NO 30205/37675	
TITLE : Pattern width slimming-inhibiting method of photoresist pattern using photoresist composition containing thermal acid generator					

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

<b>NOTICE OF ALLOWANCE MAILED</b>		Assistant Examiner		<b>CLAIMS ALLOWED</b>	
				Total Claims	Print Claim for O.G.
<b>ISSUE FEE</b>		Primary Examiner		<b>DRAWING</b>	
Amount Due	Date Paid			Sheets Drwg.	Figs. Drwg.
<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>		<b>PREPARED FOR ISSUE</b>		Application Examiner	
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